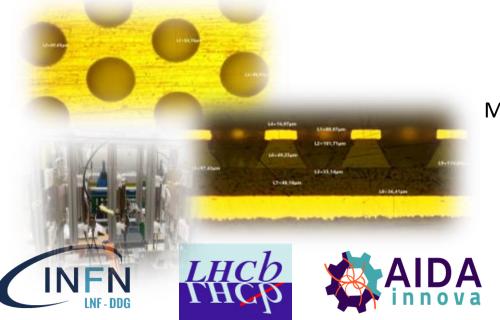




The micro-RWELL for future HEP challenges Design, Construction, Performance



G. Bencivenni¹

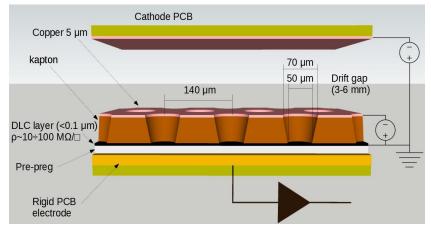
E. De Lucia¹, R. De Oliveira², G. Felici¹, M. Gatta¹, M. Giovannetti¹, G. Morello¹, E. Paoletti¹, G. Papalino¹, M. Pinamonti³, R. Pinamonti³, M. Poli Lener¹, R. Tesauro¹

1 – Laboratori Nazionali di Frascati – INFN, Frascati (IT) 2 – CERN, Meyrin (CH) 3 – ELTOS SpA, Arezzo (IT)

16th Pisa Meeting, 31st May 2024

The µ-RWELL

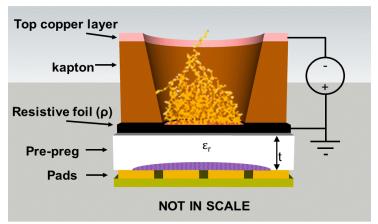
G. Bencivenni et al., The micro-Resistive WELL detector: a compact spark-protected single amplification-stage MPGD, 2015 JINST 10 P02008



The μ-RWELL is a resistive MPGD, with a GEM derived amplification stage, composed of two elements:

- Cathode
- μ-RWELLPCB:
- a WELL patterned kapton foil (with Cu-layer on top) acting as amplification stage
- − a resisitive DLC film with $\rho \sim 50 \div 100 \text{ M}\Omega/\Box$
- a standard readout PCB with pad/strip segmentation

R. Bellazzini et al., The WELL detector, Nucl. Instrum. Meth. A 423 (1999) 125.



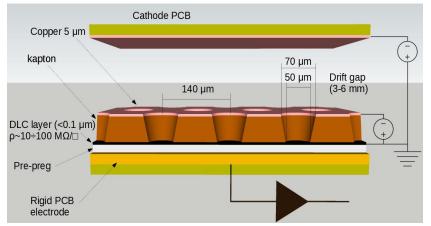
The "WELL" acts as a multiplication channel for the ionization produced in the drift gas gap.

The **resistive stage** plays a crucial role ensuring the **spark** amplitude quenching, which is **essential** for **stable** operation.

Drawback: the capability to **stand high particle fluxes** is **reduced**, but **largely recovered** with appropriate **grounding schemes** of the **resistive layer**.

The µ-RWELL

G. Bencivenni et al., The micro-Resistive WELL detector: a compact spark-protected single amplification-stage MPGD, 2015 JINST 10 P02008



The μ-RWELL is a resistive MPGD, with a GEM derived amplification stage, composed of two elements:

- Cathode
- μ-RWELL PCB:
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- a standard readout PCB with pad/strip segmentation



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The micro-Resistive WELL detector: a compact spark-protected single amplification-stage MPGD

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Laboratori Naziona

Frascati, Italy

bCERN,

Meyrin, Switzerland

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ABSTRACT: In this work we present a compact spark-protected single amplification stage Micro-Pattern Gas Detector (M detector amplification stage, realized with a structure very similar to a GEM foil, is en A cathode electrode, defining the gas conversion pletes the detector mechanics. The new structure, that we call micro-Resistive WELI has some characteristics in com mon with previous MPGDs, such as C.A.T. and WEI ore than ten years ago. The prototype object of the present study has been realized in -MPE-EM Workshop at CERN. The new architecture is a very compact MPGD, robu harges and exhibiting a large gain ($\sim 6 \times 10^3$), simple to construct and easy for engineer uitable for large area tracking devices as well as huge calorimetric apparata.

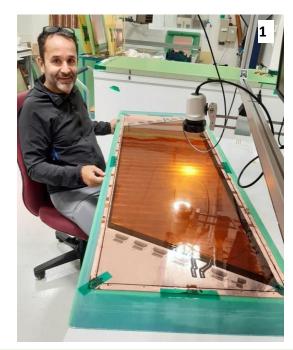
KEYWORDS: Gaseous detectors; Micropattern gaseous detectors (MSC THGEM, RETHGEM, MHSP, MICROPIC, MICROMEGAS, InGrid, etc.); Electron multiple (X-ray detectors)

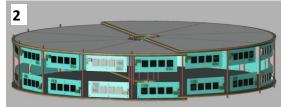
¹Corresponding author.

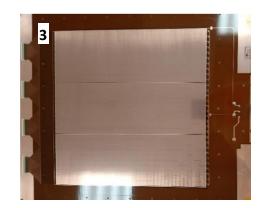
Technology spread

In the last years there has been a significant spread of the technology among several research groups working on Nuclear and Sub-Nuclear experiments

- 1. CLAS12 @ JLAB (USA): the upgrade of the muon spectrometer
- 2. EPIC @EIC (BNL USA): endcap tracker disks based on a hybrid GEM+μRWELL technology
- 3. X17 @ n TOF EAR2 (CERN): TPC with a μRWELL based amplification stage, for the detection of the X17 boson
- 4. TACTIC @ YORK Univ. (UK): radial TPC for detection of nuclear reactions with astrophysical significance
- 5. Muon collider: R&D for a digital hadron calorimeter
- **6. CMD3 (RU):** GEM+ μRWELL disk for the upgrade of the tracking system
- 7. UKRI (UK): thermal neutron detection with pressurized ³He-based gas mixtures

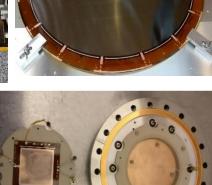












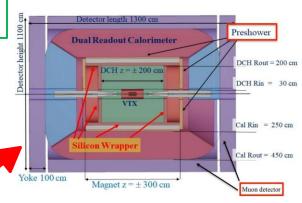


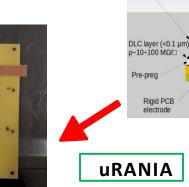
- 4

DDG - LNF R&D projects









LHCb

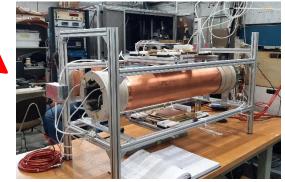
Copper 5 µm kapton

Rigid PCB electrode

EURIZON

Drift gap (3-6 mm)

$$n + {}^{10}_{5}B \begin{cases} {}^{7}_{3}Li(1.02MeV) + \alpha(1.78MeV) & 6\% \\ {}^{7}_{3}Li(0.84MeV) + \alpha(1.47MeV) + \gamma(0.48MeV) & 94\% \end{cases}$$



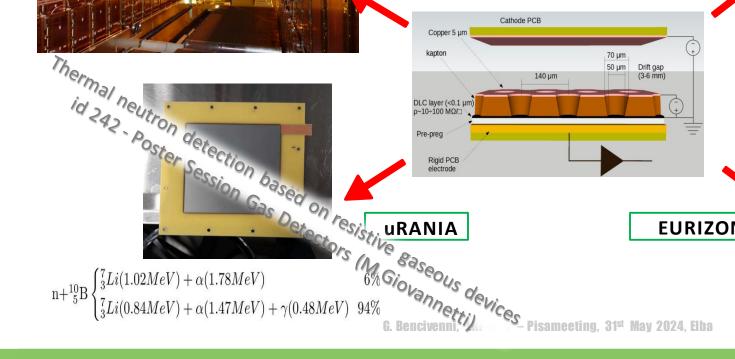
Cathode PCB

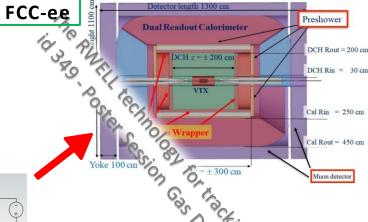
DDG - LNF R&D projects



LHCb

- rate up to 1 MHz/cm²
- 576 detectors w/pad r/out 9×9mm²
- size 30x25 to 74x31 cm²
- 90 m² detectors
- 130 m² DLC



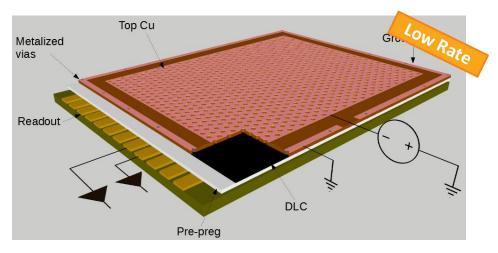


EURIZON

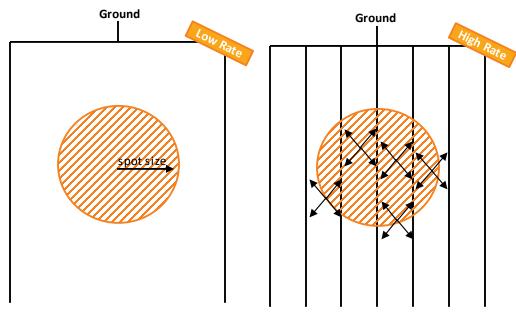
IDEA

High-rate layout: principle of operation

To overcome the **intrinsic rate limitations** of the **Single Resistive Layout,** it is necessary to introduce a **high-density grounding network** for the resistive stage (DLC).



Single Resistive Layout (SRL) with edge grounding

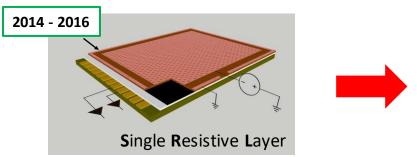


Segmenting the DLC with conductive micro-strips/dots with a typical pitch of 1cm: a sort of tiling of the active area using a set of smaller SRL.

High-rate layouts evolution

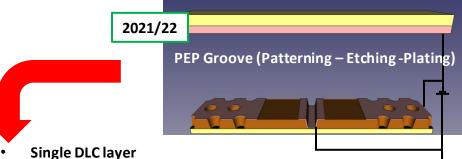
G. Bencivenni et al., The μ -RWELL layouts for high particle rate, 2019 JINST 14 P05014

Extensive R&D has been performed to optimize the DLC grounding, enabling the detector to withstand up to 1MHz/cm²

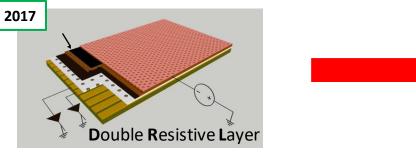


- Single DLC layer with edge conductive line
- 2-D current evacuation
- rate capability < 100 kHz/cm²
- Easy for industry

kapton foil down to the DLC

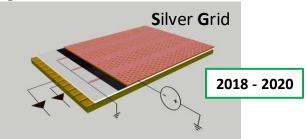


- Single DLC layer
 2-D current evacuation: conductive grid by etching from the top Cu, through the
- No grid alignment issues, scalable to large size large dead zone (>15%)
- Easily engineered, because based on SBU technology



- Two stacked resistive layers with a double matrix of conductive vias
- 3-D current evacuation
- Rate capability > 10MHz/cm²
- Complex manufacturing not easily engineered





- Single DLC layer
- 2-D current evacuation through conductive grid on the DLC layer
- rate capability > 10MHz/cm²
- Easily engineered, BUT complex Cu+DLC sputtering/alignment

PEP layouts comparison

2022

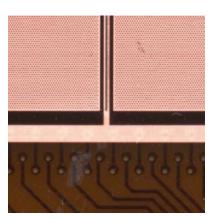
PEP-Groove:

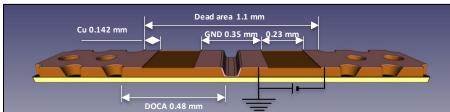
DLC grounding through conductive groove to ground line

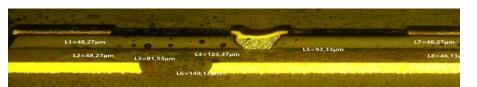
Pad R/O = **9×9mm**²

Grounding:

- Groove pitch = 9mm
- width = 1.1mm
- → 84% geometric acceptance







2023

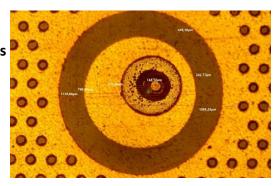
PEP-DOT:

DLC grounding through conductive dots connecting the DLC with pad r/outs

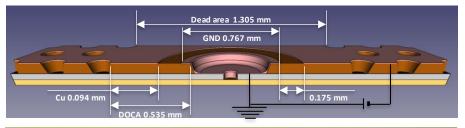
Pad R/O = $9 \times 9 \text{mm}^2$

Grounding:

- Dot pitch = 9mm
- dot rim = 1.3mm
- → 97% geometric acceptance



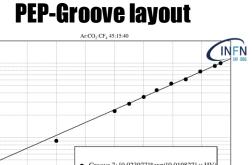
DOT ≈ plated blind vias



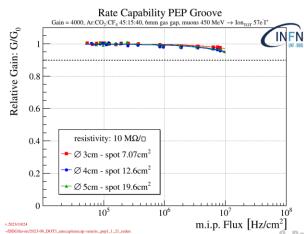


Groove vs DOT (X-ray characterization)

2022



Gas gain Groove 7: [0.023977]*exp([0.019827] × HV] 520 620 HV [V] v:2023/11/17 -/DDG/lavori/2023-09_DOT3_ratecap/2023-09_gain_PEP_DOT_GROOVE/gain_dot_groo



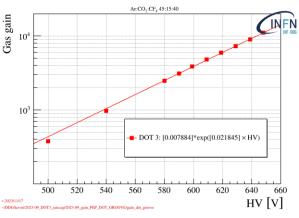
2023

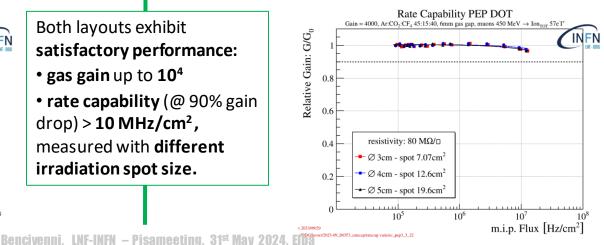


Both layouts exhibit satisfactory performance:

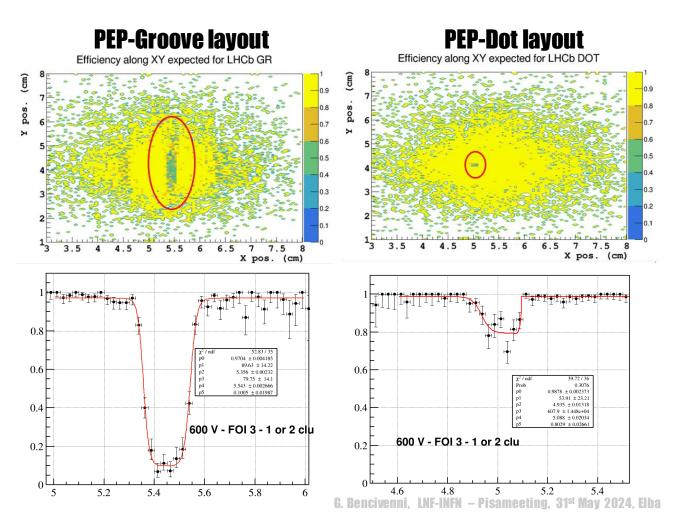
- gas gain up to 104
- rate capability (@ 90% gain $drop) > 10 MHz/cm^2$, measured with different irradiation spot size.

PEP-DOT layout

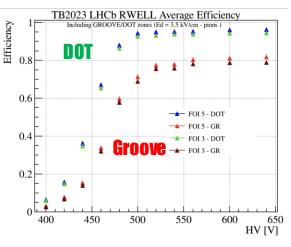


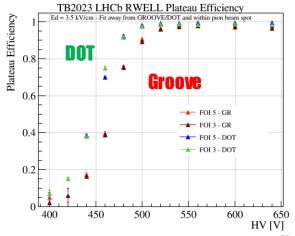


Groove vs DOT (test beam characterization)



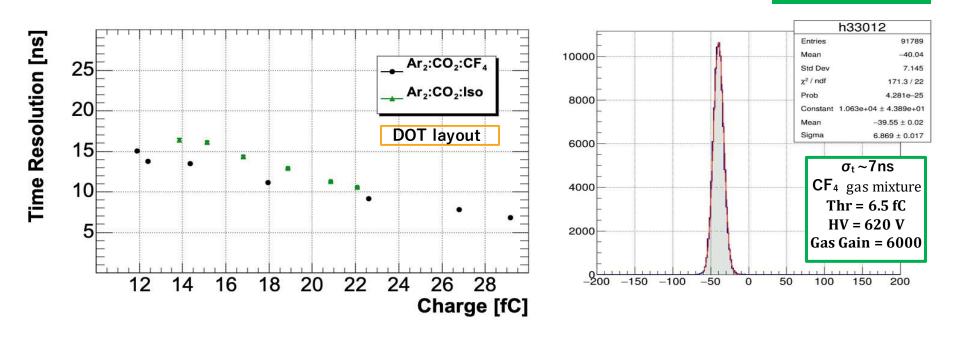
APV25 based Fee





PEP DOT – time performance (preliminary)

FATIC based Fee



TB-2023 at H8C with preliminary version of the FATIC chip (developed by Bari Group) in the framework of the R&D for the LHCb-Muon upgrade. A new test beam foreseen next Nov. '24 with an updated version of the ASIC, aiming to reduce the FEE thr down 3 – 3.5 fC

Manufacturing high-rate layouts

The **PEP-DOT layout is a rigid-flex PCB** uses an **SBU technology-based PCB**, that is **compatible with standard industrial processes**.

The **ELTOS** is the industrial partner **involved** in the manufacturing of the μ -RWELL.

This presents a significant advantage, in view of large-scale production for the Muon upgrade at LHCb.

The **ELTOS SpA** was founded in 1980 in Arezzo, Italy.

The Company has a large experience in the construction of MPGDs, including technologies such as Thick-GEM (THGEM) and MicroMegas.

The involvement of a private industry in this R&D opens the way for the use of μ -RWELL technology across various fields of applications.





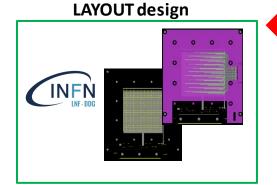






Detector Manufacturing flow chart





DLC foil production

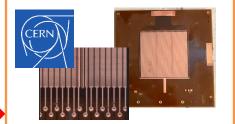


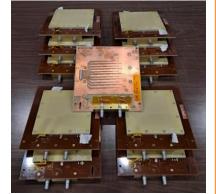
Feedback from tests

PCB production



Final detector manufacturing





Detector manufacturing steps



Step 0 - Detector PCB design @ LNF



- In operation since Nov. 2022
- Production by LNF-INFN technical crew



Step 2 – Producing readout PCB by **ELTOS**

pad/strip readout



• photo-resist → patterning with BRUSHING-machine



• Large press available, up to 16 PCBs workable simultaneously



Step 5 – Top copper patterning by CERN

Cu amplification holes image and HV connections by Cu etching



PI etching → amplification-holes

Step 7 – Electrical cleaning and detector closure @ CERN





DLC sputtering



The **CID** (CERN-INFN-DLC) sputtering machine, a **joint project between CERN and INFN**, is used for preparing the **base material of the detector**. The potential of the DLC sputtering machine is:

- Flexible substrates up to 1.7m×0.6m
- Rigid substrates up to 0.2m×0.6m

In **2023**, the activity on CID focused on the **tuning** of the **machine on small foils**: very **good** results in terms of **reproducibility and uniformity**.

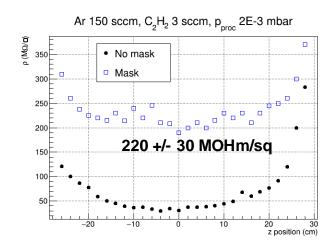
In 2024, the challenge is the sputtering of large foils.

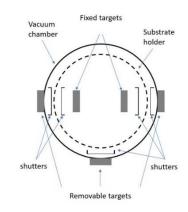
C.I.D.











Machine co-funded by CERN and INFN. R&D led by INFN LNF, Roma3 and Naple

The graphite target

Detector manufacturing at ELTOS (1)

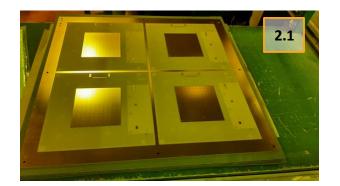


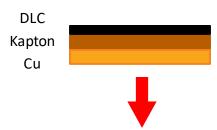
Step 2 (@ ELTOS)

1) PCB production

Step 3 (@ ELTOS)

- 1) Photoresist lamination for DLC protection
- 2) Photoresist UV-exposure
- 3) Photoresist developing
- 4) DLC patterning with brushing machine











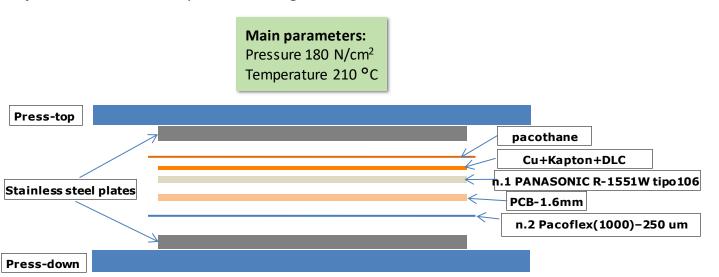


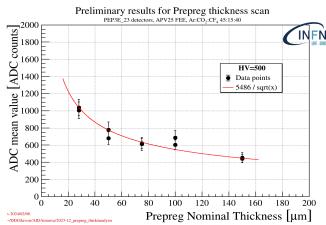
Detector manufacturing at ELTOS (II)

Step 4: The final manufacturing operation carried out at ELTOS is the **coupling of the DLC foil** and the PCB through a layer of prepreg.

N. 16 prototypes of micro-RWELL were made with 4 different prepreg thicknesses (\oplus 1 special). The test, beside validating the whole manufacturing process (ELTOS \oplus CERN), allowed for the study of the dependence of the induced signal amplitude as a function of the readout capacitance wrt the amplification stage.

Pre-preg	Δx [μm]
106	50
1080	75
x2 106	100
x2 1080	150





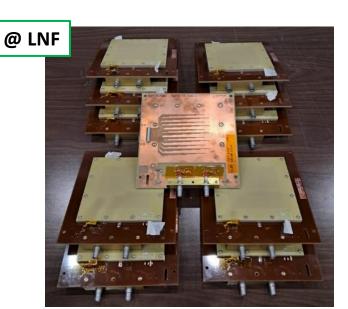
Electrical Hot Cleaning



At the end of the manufacturing process at CERN, a **conditioning procedure** is performed:

- Standard PCB washing
- Electrical cleaning in dry air (90°C in an oven) from 300 V to
 680 V (each step with current < 1 nA)
- Detector closure and final test at 600 V in ambient air

Pilot co-production test



The 16 co-produced prototypes have been extensively tested with X-rays:

- 15/16 are fine
- 1/16 needs re-cleaning

Production yield > 93%

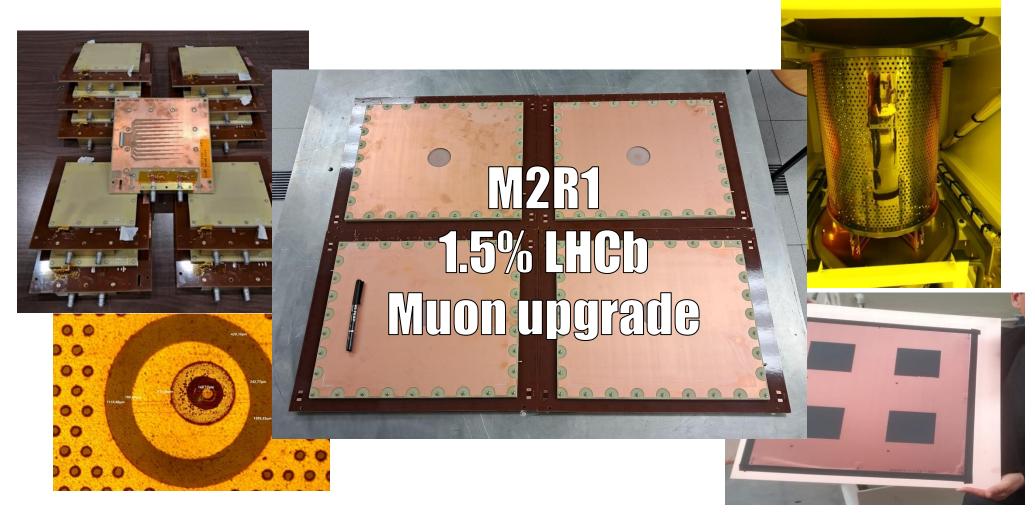
Summary & Outlook

The **R&D** on **high-rate layouts for the LHCb upgrade** has been completed:

- the **PEP-DOT** layout shows good performance: gain of **10**⁴, **98**% efficiency, **> 10 MHz/cm**², **7ns** time resolution
- General parameters of the detector have been set to maximize stability and gain:
 - $\rho \ge 50$ MOhm/square, DOCA = 0.5 0.6mm (dead-zone ~ 1.3mm)
 - prepreg thickness ~ 28μm
 - Amplification stage optimization by reducing the well pitch: 140μm, 110μm, 90μm
- Large size:
 - M2R1-LHCb (25x30 cm² active area): delivered mid-May '24, X-ray characterization in June, test beam in Nov. '24.
 - M2R2-LHCb (30x70 cm² active area): design by the end of 2024, production beginning in 2025

The **detector manufacturing process** is nearly finalized:

- Several construction steps are performed by ELTOS
- Detector finalization (Kapton etching, electrical hot cleaning, etc.) is carried out at CERN
- The **DLC sputtering machine**, C.I.D., **will provide the base material**, once the sputtering parameters are optimized





SPARE SLIDES

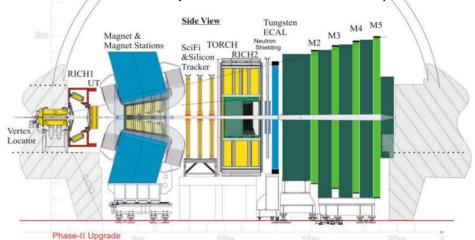
μ-RWELL at LHCb

Inner region @ Run5 – Run6 detector requirements^[1]

- Rate up to 1 MHz/cm² on detector single gap
- Rate up to 700 kHz per electronic channel
- Efficiency quadrigap >=99% within a BX (25 ns)
- Accumulated charge in 10y at M2R1 up to 1C/cm²

Detector size & quantity (4 gaps/chamber - redundancy)

• R1÷R2: 576 detectors, size 30x25 to 74x31 cm², 90 m² detectors -130 m² DLC



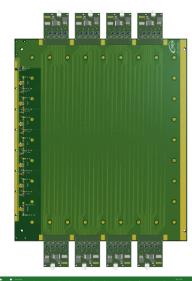


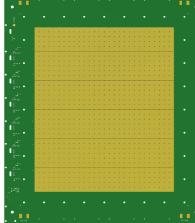
66493	120583	148811	77788					
99470	217584	255560	107048					
147585	321062 <mark>538980</mark>	508077 340550	170105					
187623	594044	573691	205862					
193571	496249	549110	217988					
143561	341093 <mark>558687</mark>	546084 344551	152596					
103585	209874	248696	114114					
65005	122387	135696	73421					

[1] CERN-LHCC-2021-012; LHCB-TDR-023 http://cds.cern.ch/record/2776420?ln=it

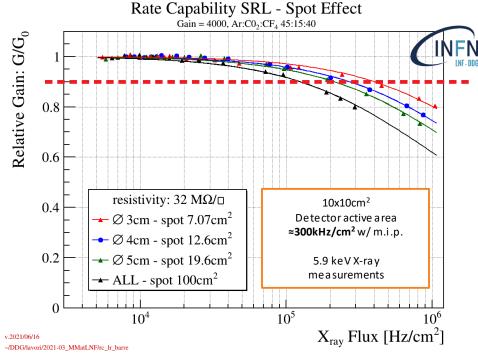
High-rate µ-RWELL – R&D plans

- ✓ M2R1 design delivered mid-May 2024
- M2R1 X-ray characterization (June- July 2024)
- Electronic integration, FATIC3 chip based (Sept. 2024)
- Test beam (NA H8C CERN or T10-PS) M2R1 with FATIC3 (Nov. 2024)
- R&D plans:
 - amplification stage optimization (gain vs well-pitch)
 - optimization coupling DLC foil R/out PCB
 - test of Hybrid layout → G-RWELL
 - electrical cleaning optimization (w/Rui)
 - irradiation study a GIF++ (w/CERN Gas Group)





The SRL resistive model



FLOW:

Different primary ionization ⇒ Rate Cap.m.i.p. = 3×Rate Cap.x-ray

DATA Extrapolation $\frac{G}{G_0} o p_0 o \Omega o \phi_{90\%}$

 $\Omega(r) = \rho_S \frac{d - \frac{r}{2}}{\pi \cdot r}$

$$\phi_{90\%} = \frac{\Delta V_{drop\;10\%}}{e\cdot N_0\cdot G\cdot Spot\cdot \Omega}$$

← ΔVdrop 10% from the gain measurement

Validation

$$\phi_{90\%} \approx \frac{1}{\rho_S \cdot r \, (d - r/2)}$$

 $\frac{G}{G_0} = \frac{-1 + \sqrt{1 + 4p_0\phi}}{2p_0\phi}$

SPOT [cm ²]	p_0
12.6	1.4656E-6
19.5	2.0224E-6

$$\Omega(r) = \frac{p_0(r)}{\alpha \cdot e \cdot N_0 \cdot G \cdot \pi \cdot r^2}$$

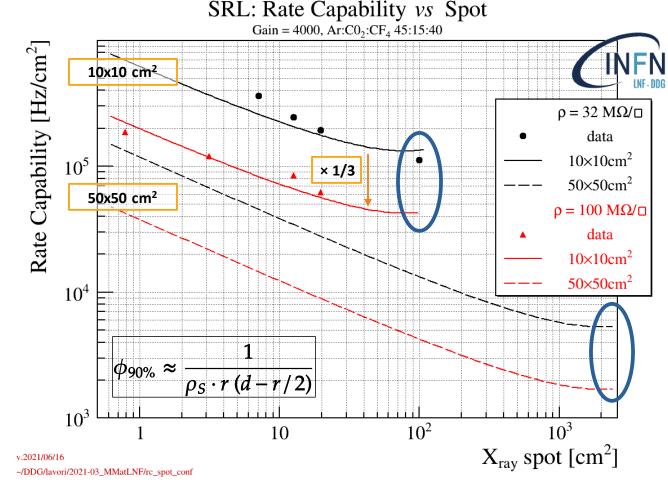
G. Bencivenni et al., JINST 10 (2015) P02008

Spot Effect for SRL – Manufacturer plot

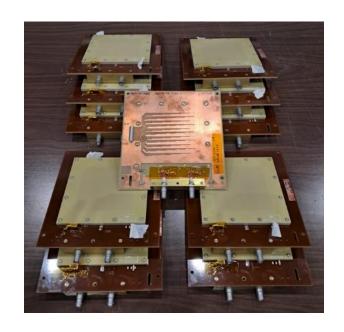
From the mathematical model:

- 1. detectors with same size but different resistivity exhibit a rate capability scaling as the inverse of their resistivity.
- 2. for the SRL, increasing the active area from 10x10 cm² to 50x50 cm² the rate capability should go down to few kHz/cm²
- 3. By using a DLC ground sectoring every 10 cm, large (50x50 cm²) detectors could achieve rate capability up to 100kHz/cm² (with X-ray)

Different primary ionization ⇒
Rate Cap.m.i.p. = 3×Rate Cap.x-ray



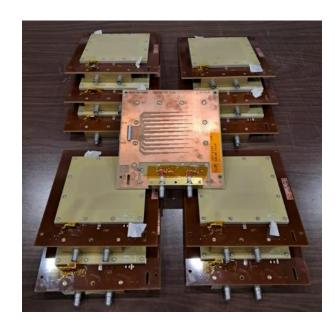
Co-production pilot test



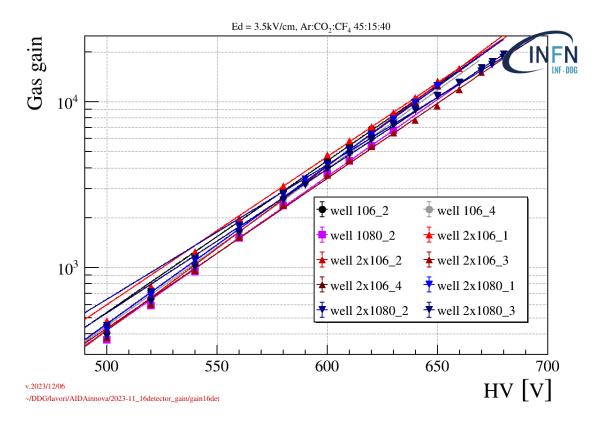
- 16 co-produced protos have been delivered and tested
- 10/16 (LNF) + 5/16 (CERN) are fine
- 1/16 should be re-cleaned

Detector #	Prepreg type	DLC resistivity	Production status	Max HV/Gain	comments	
106_1	1x 106		Cleaning		@ CERN	
106_2	1x 106	7.5	Delivered	640/10000		
106_3	1x 106		Cleaning		@ CERN	
106_4	1x 106	7	Delivered	640/9500		
1080_1	1x10.00		Cleaning		© CERN	
1080_2	1x1080	4.8	Delivered	630/6700		
1080_3	1x1080	5	Delivered	n.a.	To be re-cleaned	
1080_4	1x10.00		Cleaning		© CERN	
2x106_1	2x106	35	Delivered	660/16000		
2x106_2	2x106	37	Delivered	650/13000		
2x106_3	2x106	35	Delivered	670/15000		
2x106_4	2x106	34	Delivered	650/12500		
2x1080_1	2x1080	33	Delivered	670/19500		
2x1080_2	2x1080	110	Delivered	680/19000		
2x1080_3	2x1080	44	Delivered	680/19000		
2x1080_4	2x1080		Cleaning		@ CERN	

Co-production pilot results (1)

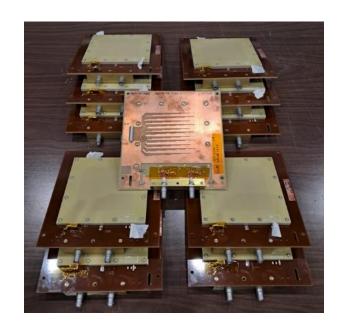


- 16 co-produced protos have been delivered and tested
- 10/16 (LNF) + 5/16 (CERN) are fine
- 1/16 should be re-cleaned

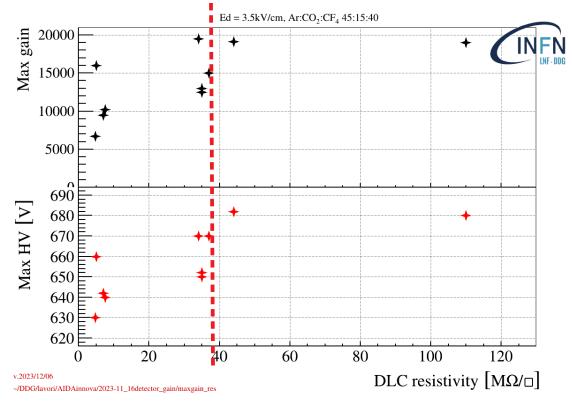


Characterized with **X-ray gun** → **Gas gain** measurement

Co-production pilot results (II)



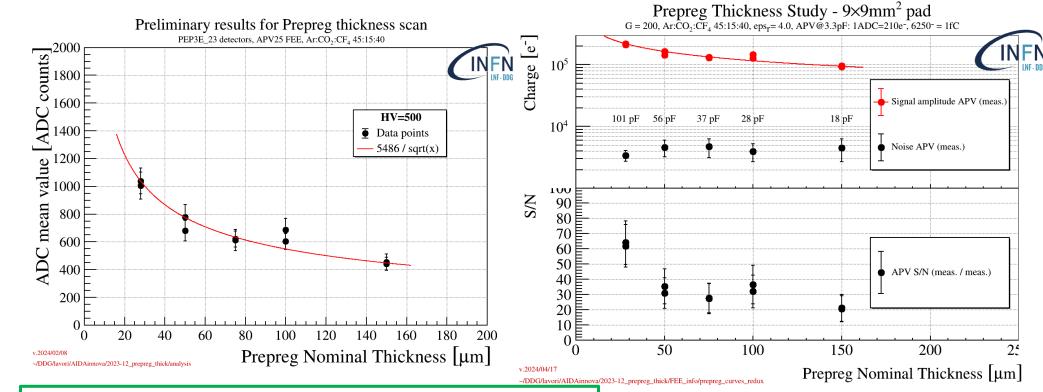
- 16 co-produced protos have been delivered and tested
- 10/16 (LNF) + 5/16 (CERN) are fine
- 1/16 should be re-cleaned



The maximum gain is larger for $\rho \ge 30$ MOhm/square

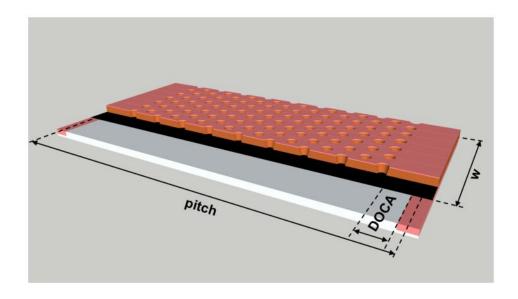
Prepreg thickness optimization





28µm thick prepreg maximize both the amplitude of the signal induced on the pad readout, and S/N ratio (measurement done with APV25)

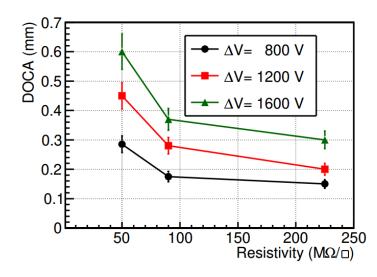
DLC surface discharges - DOCA



Cross-section of a μ -RWELL with a conductive line on the DLC (High-Rate scheme).

The concept of **DOCA** (distance-of-closest-approach) before discharge is fundamental for the **stability** of the detector.

The **DOCA** is defined as the **distance between** the edges of the **conductive lines** and its **closest amplification hole**.



The **DOCA (before discharge)** as a function of the DLC **resistivity**, for different **voltages**.

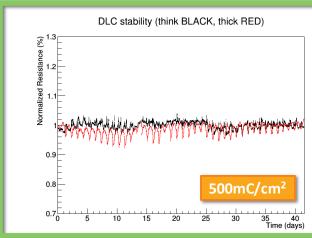
The study has been performed with a custom tool, with two thin conductive movable tips.

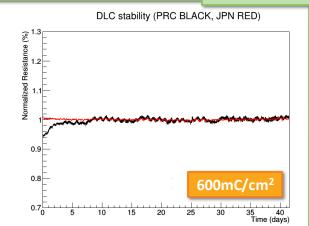


Irradiation test of DLC and μ -RWELL

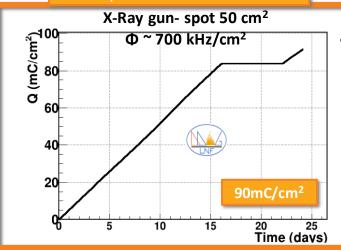
Bare DLC foils

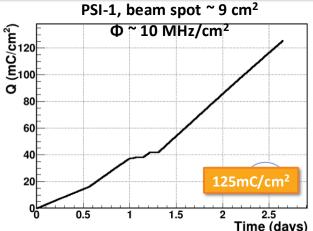
- **DLC foils**: monitoring of the resistivity of two foils under x-ray irradiation.
- μ-RWELL detectors: prototypes irradiated with different radiation.

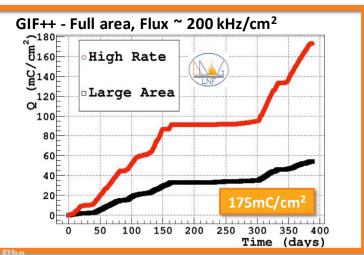




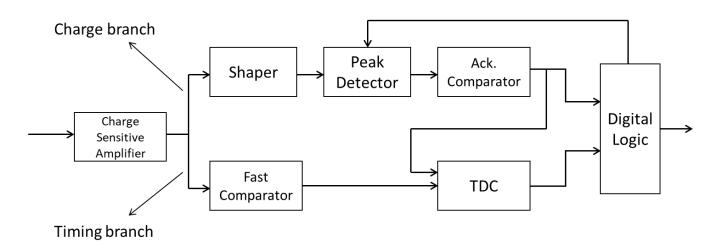
μ-RWELL DETECTORS







FATIC2 block diagram



Preamplifier features:

- CSA operation mode
- Input signal polarity: positive & negative
- Recovery time: adjustable

CSA mode:

- Programmable Gain: 10 mV/fC ÷ 50 mV/fC
- Peaking time: 25 ns, 50 ns, 75 ns, 100 ns

Timing branch:

- ✓ Measures the arrival time of the input signal
- ✓ Time jitter: 400 ps @ 1 fC & 15 pF (Fast Timing MPGD)

Charge branch:

- ✓ Acknowledgment of the input signal
- ✓ Charge measurement: dynamic range > 50 fC, programmable charge resolution

μ-RWELL + GEM

Nuclear Inst. and Methods in Physics Research, A 936 (2019) 401-404



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Development of μ -RWELL detectors for the upgrade of the tracking system of CMD-3 detector



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ARTICLE INFO

Keywords: Tracking detectors Micro-RWELL Micro-pattern gas detectors

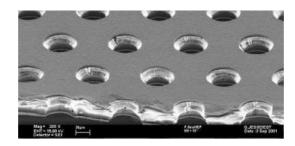
ABSTRACT

An upgrade of tracking system of Cryogenic Magnetic Detector (CMD-3) is proposed using microresistive WEIL technology. CMD-3 is a general purpose detector operating at the VEPP-2000 collider at Budker Institute of Nuclear Physics and intended for studies of light vector mesons in the energy range between 0.3 GeV and 2 GeV. The new subsystem consists of double-layer cylindrical detector and the end-cap discs. Two prototypes, micro-RWEIL and micro-RWEIL-GEM were built and tested. Gas amplification of micro-RWEIL detector was measured with several gas mixtures and maximum gain between 20000 and 30000 was observed. However, maximum gain is fluctuating from measurement to measurement by a factor of 2 and thus a safety margin of 2-3 is needed to provide reliable operation of the device. In order to increase the signal GEM was added to micro-RWEIL, new prototype was tested with the same gas mixtures and gains above 10⁵ have been demonstrated. Time resolution achieved for both prototypes are 7 ns for micro-RWEIL and 4 ns for micro-RWEIL-GEM.

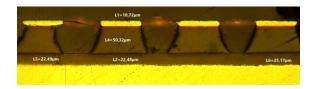
L. Shekhtman, Nuclear Inst. and Methods in Physics Research, A 936 (2019) 401-404



Drift Gap: Shekhtman 3mm - LNF+Roma2 6mm



Transfer Gap: Shekhtman 3mm – LNF+Roma2 3mm



Developed for CMD3 upgrade disks (4 sectors 50×50cm²)

The GEM **must be** stretched: sizes larger than 50×50cm² could be critical (depending on the gas gaps size).

μ-RWELL + GEM: gas gain

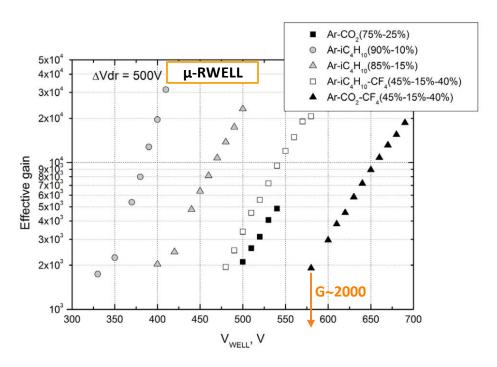


Fig. 4. Gain as a function of voltage on the top electrode of μ -RWELL for different gas mixtures. Voltage across the drift gap is 500 V.

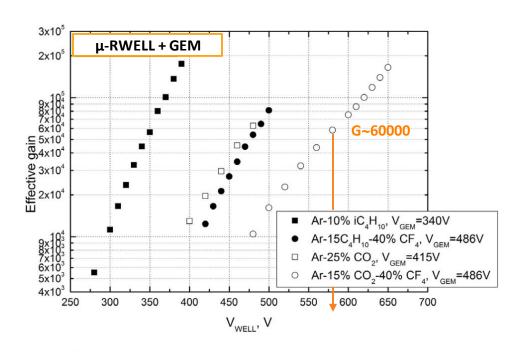


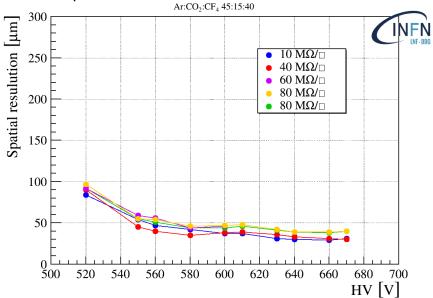
Fig. 5. Gain as a function of voltage on the top electrode of μ -RWELL for GEM voltages providing additional gain of 50–100 and for different gas mixtures. Voltage across the drift gap is 500 V.

L. Shekhtman, Nuclear Inst. and Methods in Physics Research, A936 (2019) 401-404

1-D Tracking

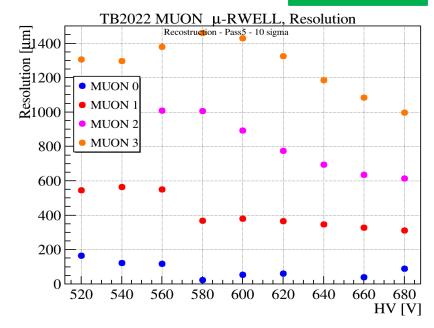
Resistivity scan

RD-FCC μ-RWELL, Residuals test resolution - 75ADC threshold



With a **0.4 mm strip pitch** and **0.15 mm strip width**, no effects were observed within this resistivity range. Additionally, DLC resistivity uniformity is not a critical parameter for spatial resolution.

R/O pitch scan

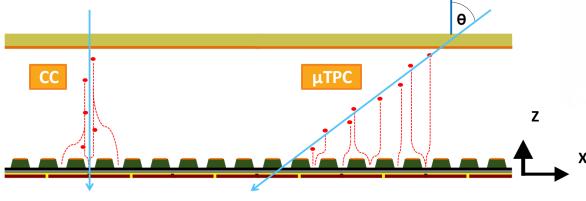


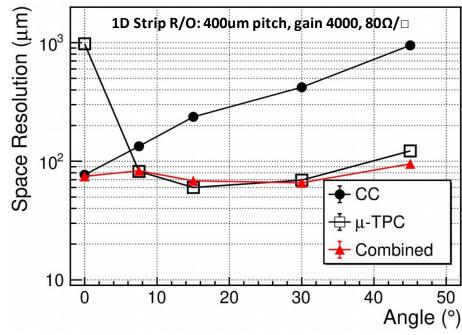
Increasing the R/O pitch will result in a reduction of the spatial resolution

1-D tracking (inclined tracks)

For inclined tracks and/or in presence of high B fields, the charge centroid (CC) method gives a very broad spatial resolution on the anode-strip plane.

Implementing the μTPC mode^[1], using the knowledge of the drift time of the electrons each ionization cluster is projected inside the conversion gap, and the track segment in the gas gap is reconstructed.





Combining the CC and μTPC reconstruction (through a wheighted average) a resolution well below 100 μm could be reached over a wide incidence angle range.

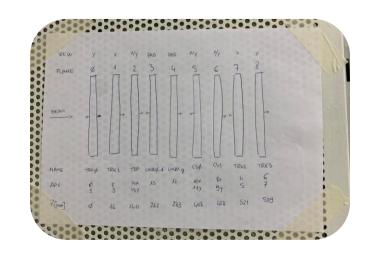
[1] introduced for ATLAS MMs by T. Alexopoulos

M. Giovannetti et al., On the space resolution fo the μ -RWELL, 2020 JINST 16 P08036

2-D Tracking

R&D on tracking μ-RWELL for muons systems

- 2 ⊗ 1D layout
- 2D \rightarrow 1D \oplus top-readout
- 2D w/Capacitive Sharing

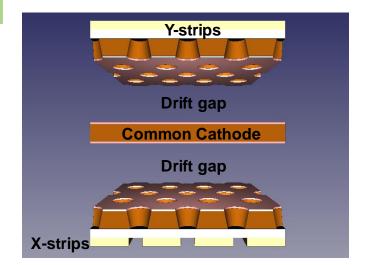


- Ar-CO2-CF4 mixture
- APV readout / No time information available
- External tracking with X&Y strip upstream and downstream chambers



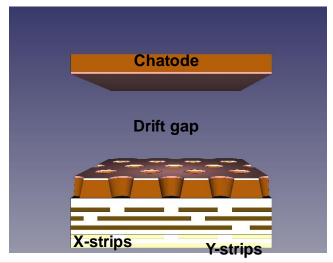
2-D Tracking layouts

N.2 u-RWELLS 1D (2⊗1D)



Operation at **lower gas gain** wrt the «COMPASS» R/out (X-Y r/out decoupled) **Tested @ TB2022**

u-RWELL - Capacitive Sharing r/out



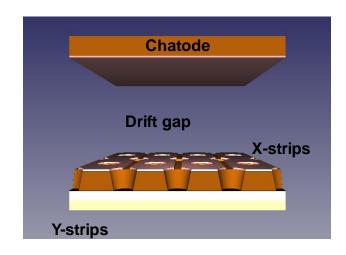
The charge sharing performed through the capacitive coupling between a stack of layers of pads and the r/out board.

Reduce the FEE channels, but the total charge is divided between the X & Y r/out.

Tested @ TB2023

G. Bencivenni, LNF-INFN - Pisameeting, 31st May 2024, Elba

u-RWELL TOP r/out

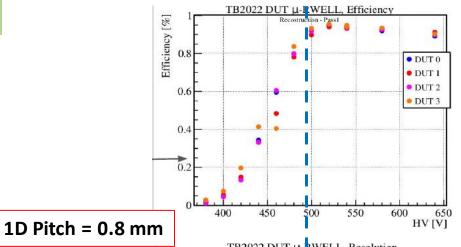


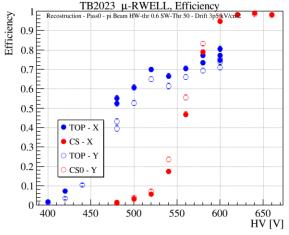
The **TOP-readout layout** allows to work at **low gas gain** wrt the «COMPASS» r/out (X-Y r/out decoupled).

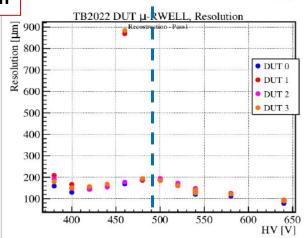
X coordinate on the TOP of the amplification stage introduces **dead zone** in the active area.

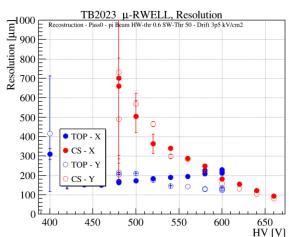
Tested @ TB2023

Tracking performance









CS pitch 1.2 mm

- due to the charge spread the working point is shifted to high voltage/gain
- Spatial resolution improves at high gain reaching 150 um with a strip pitch of 1.2 mm

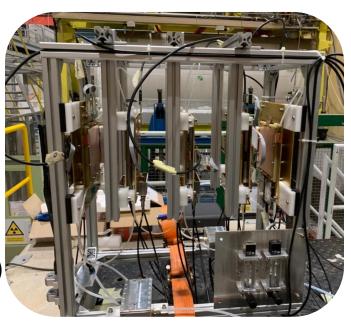
Top-r/out pitch 0.8 mm

low-voltage/gain
 operation but low
 efficiency level due to
 the geometrical dead
 zone on the segmented
 amplification stage

Tracking: R&D plans

R&D on tracking μ-RWELL for muons systems at future colliders

- Finalization of the analysis of the 2022-2023 beam tests:
 - 2 ⊗ 1D layouts
 - 2D \rightarrow 1D \oplus top-readout
 - 2D w/Capacitive Sharing
- R&D plans:
 - amplification stage optimization (gain vs well-pitch)
 - new PCB-RWELL multi-task layout (1D, 2D, Hybrid layouts)
 - hybrid μ -RWELL \rightarrow GEM \oplus RWELL
 - TB-2024 (sinergy with INFN Roma2)



Low X₀ Cylindrical µ-RWELL



Exploiting the **flexible characteristic of the amplification stage** of the μ -RWELL, as well as the readout (to which it is coupled through the resistive DLC stage), we developed **a low-mass (0.6% X0) modular Inner Tracker for low-energy positron-electron colliders**, exploiting the **innovative Cylindrical** μ -RWELL (C-RWELL) technology.



Three roof-tile layout



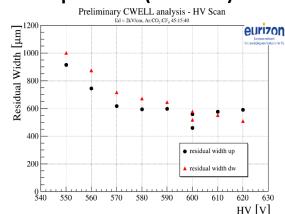
Vacuum bag technology



Roof-tiles assembly

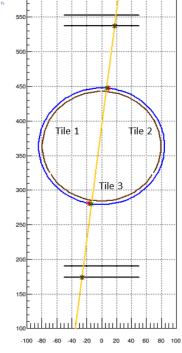


C-RWELL test with cosmics





Dinner with Huong



Low Mass µ-RWELL

		Thikcness (um) X0 (cm)	% xo			Glue	0	33.5	0.000
	Cu Ground FEE	3	1.43			Tile BaseLine	kapton	0	28.6	0.000
٠,	kapton	50	28.6	0.017			Glue	0	33.5	0.000
Anode Support	glue	25	33.5	0.007			MILLIFOAM	0	1312.5	0.000
	FR4	100	19.3	0.052			Glue	0	33.5	0.000
<u> </u>	glue	25	33.5	0.007			Kapton	0	28.6	0.000
2	MILLIFOAM	3000	1312.5	0.023						0.000
₹	glue	25	33.5	0.007						
	FR4	100	19.3	0.052					Tot. Anode	0.378
				0.187						
) Poc	Cu	3	1.43	0.021
						gt	kapton	50	28.6	0.017
stage	Cu	5	1.43			ar. Cageathode Support + Cathod	glue	25	33.5	0.007
sta	kapton	50	28.6				FR4	100	19.3	0.052
Amp.	DLC	0.1	12.1				glue	25	33.5	0.007
Ā	Pre-preg (106)	50	19.3				MILLIFOAM	3000	1312.5	0.023
				0.078		b	glue	25	33.5	0.007
						Far. Cageath	FR4	100	19.3	0.052
							glue	25	33.5	0.007
	Cu	5	1.43				kapton	50	28.6	0.017
20	kapton	50	28.6				Cu Ground	3	1.43	0.021
Anode 2D	glue	25	33.5							0.233
Αŭ	Cu	5	1.43	0.035						
	kapton	50	28.6	0.017					X0 - singl¢	0.611
				0.112					X0 B2B	0.99

Footer 45